Integrated Equipment Data Collection and Management for Smart Manufacturing

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Outline

- Key messages
- Smart Manufacturing context
- Factory stakeholders
- Equipment model value chain
- SEMI Standards support
- Integrated data management
- Application examples





Key messages

- R
- Stakeholder needs drive all requirements
- Equipment models are key technology
 - Content determines system capability
 - Management tools determine user experience
- Service-oriented architectures enable smooth technology evolution through decoupling
- Current SEMI Standards provide direct support
- Consistent user experience is vital for stakeholder satisfaction and system adoption
- Chinese semiconductor industry is in perfect position to leverage all the above





What is "Smart Manufacturing?" From Industry 4.0 Wikipedia...

- "... cyber-physical systems monitor physical processes, create a virtual copy of the physical world and make decentralized decisions.
- Over the Internet of Things, cyber-physical systems communicate and cooperate with each other and with humans in real time..."









Equipment model value chain Fundamental concept for application integration



SEMI Standards support Why is E164* so important?

- Consistent implementations of GEM300
- Commonality across equipment types
- Automation of data collection processes
- Less work to interpret collected data
- Enables true "plug and play" applications
- Major increases in engineering efficiency

E164 is to EDA what GEM was to SECS-II





* EDA Common Metadata standard



Equipment data management Integrated production system architecture

SECSConnect[™] CIM300

CIM

EDAConnect¹⁰ ECCE

CIM

SEC5CO

CIM300



Equipment data management Major system components

- Model Manager
- Plan Manager
- Equipment Gateway
- Data Mapper
- Data Router
- Data Repository
- Data Scope
- Synchronization Engine
- Performance Monitor
- Administrator Toolkit







New manufacturing applications Current leading edge

- Real-time throughput monitoring
- Precision FDC feature extraction
- Specialty sensor data access
- Fleet matching and management
- eOCAP execution support
- Sub-fab data integration/analysis
- Automated equipment characterization

Wide range of stakeholder coverage







Application example Real-time throughput monitoring



- Problem statement
 - Monitor bottleneck (e.g., litho) tool throughput performance to know when it drifts away from "normal" for whatever reason
 - This is important because any loss of throughput ripples throughout the line
- Solution components
 - Monitor events and calculate process time "on the fly"
 - Evaluate context to compare "equivalent" runs; flag outliers
- Equipment model leverage
 - Standard material movement and recipe execution events
 - Context available at event occurrence
- Key ROI factors
 - Cycle time, productivity excursion MTTD (50% reduction), equipment throughput improvement (3-5%)





Real-time throughput monitoring SEMI E90 state machines and model







SECSCO

CIMBOO

CIMP

EDAConnect

ECCE

Plus

CIM

SECS

CIM300

CIM



🗄 🔂 Substrate, E90-0707



Thank you

- 謝謝
- 감사합니다
- Merci
- Danke
- 多謝
- ありがとうございます
- Gracias



